

Title (en)

PRINTING STENCIL FOR APPLYING A PRINTING PATTERN TO A SUBSTRATE, AND METHOD FOR PRODUCING A PRINTING STENCIL

Title (de)

DRUCKSCHABLONE ZUM AUFBRINGEN EINES DRUCKMUSTERS AUF EIN SUBSTRAT UND VERFAHREN ZUM HERSTELLEN EINER DRUCKSCHABLONE

Title (fr)

GABARIT D'IMPRESSION PERMETTANT D'APPLIQUER UN MOTIF D'IMPRESSION SUR UN SUBSTRAT ET PROCÉDÉ DE FABRICATION D'UN GABARIT D'IMPRESSION

Publication

**EP 2668040 A1 20131204 (DE)**

Application

**EP 12702425 A 20120127**

Priority

- DE 102011003287 A 20110127
- EP 2012000363 W 20120127

Abstract (en)

[origin: WO2012100951A1] The present invention relates to a printing stencil (2), for example for applying a contact (contact fingers 101, busbar/ busbars 102) to a substrate (1) of a solar cell (100) and to a method for producing a printing stencil (2) of this type. The printing stencil (2) comprises a carrier layer (21) and a structure layer (22) which lies under the carrier layer (21), wherein the structure layer (22) has at least one printing image opening (23a) which corresponds to at least part of the printing image of the contact (contact fingers 101, busbar/busbars 102), the carrier layer (21) has one or more carrier layer openings (23b), and the one or more carrier layer openings (23b) overlap in a plan view of the printing stencil (2) with the printing image opening (23a), in such a way that the printing stencil (2) has an opening (23) which is formed from the at least one printing image opening (23a) and the one or more carrier layer openings (23b) and is suitable for applying contact material to the substrate (1) through the opening (23).

IPC 8 full level

**B41F 15/36** (2006.01); **H05K 3/12** (2006.01)

CPC (source: EP US)

**B23K 26/38** (2013.01 - EP US); **B23K 26/40** (2013.01 - EP US); **B41F 15/36** (2013.01 - EP US); **B41N 1/24** (2013.01 - EP US);  
**H01L 31/022425** (2013.01 - EP US); **B23K 2103/172** (2018.07 - EP US); **B41C 1/145** (2013.01 - EP US); **B41C 1/147** (2013.01 - EP US);  
**H05K 3/1225** (2013.01 - EP US); **Y02E 10/50** (2013.01 - EP US)

Citation (search report)

See references of WO 2012100951A1

Designated contracting state (EPC)

AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

DOCDB simple family (publication)

**DE 102011003287 A1 20120802;** CN 103347695 A 20131009; EP 2668040 A1 20131204; US 2014076231 A1 20140320;  
WO 2012100951 A1 20120802

DOCDB simple family (application)

**DE 102011003287 A 20110127;** CN 201280006763 A 20120127; EP 12702425 A 20120127; EP 2012000363 W 20120127;  
US 201213980962 A 20120127